

Inventor Information

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Application Information

Title Line One:: Method Of Manufacturing
Title Line Two:: Semiconductor Device, Molding Device
Title Line Three:: For Semiconductor Device, And
Title Line Four:: Semiconductor Device

Total Drawing Sheets:: 6
Docket Number:: 104788

Continuity Information

>This application is a:: U.S. National Stage of
Application One:: PCT/JP99/01520
Filing Date:: March 25, 1999
Patent Number::
which is a::
>>Application Two::
Filing Date::
Patent Number::

Prior Foreign Applications

Foreign Application One:: 10-79874
Filing Date:: March 26, 1998
Country:: Japan
Priority Claimed:: yes
Foreign Application Two::
Filing Date::
Country::
Priority Claimed::
Foreign Application Three::
Filing Date::
Country::
Priority Claimed::

PCT REQUEST

EPPC-1778

Draft (NOT for submission) - printed on 23.11.1999 03:34:48 PM

0	Form receiving Office use only	
0-1	International Application No.	
0-2	International Filing Date	
0-3	Name of receiving Office and "PCT International Application"	
0-4	Form - PCT/RO/101 PCT Request Prepared using	PCT-EASY Version 2.90 (updated 15.10.1999)
0-5	Petition The undersigned requests that the present international application be processed according to the Patent Cooperation Treaty	
0-6	Receiving Office (specified by the applicant)	Japanese Patent Office (RO/JP)
0-7	Applicant's or agent's file reference	EPPC-1778
I	Title of invention	METHOD FOR MANUFACTURING SEMICONDUCTOR DEVICE, MOLDING DEVICE FOR SEMICONDUCTOR DEVICE, AND SEMICONDUCTOR DEVICE
II	Applicant	
II-1	This person is:	applicant only
II-2	Applicant for	all designated States except US
II-4	Name	SEIKO EPSON CORPORATION
II-5	Address:	4-1, Nishi-shinjuku 2-chome Shinjuku-ku, Tokyo 163-0811 , Japan
II-6	State of nationality	JP
II-7	State of residence	JP
II-8	Telephone No.	03-3348-3114
II-9	Facsimile No.	03-3340-4258
III-1	Applicant and/or inventor	
III-1-1	This person is:	applicant and inventor
III-1-2	Applicant for	US only
III-1-4	Name (LAST, First)	SATO, Akira
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III-1-7	State of residence	JP

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IV-1	Agent or communication representative; r address for correspondence The person identified below is hereby/has been appointed to act on behalf of the applicant(s) before the competent International Authorities as:	agent
IV-1-1	Name (LAST, First)	INOUE, Hajime
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IV-1-5	e-mail	MXJ00663@nifty.ne.jp
IV-2	Additional agent(s)	additional agent(s) with same address as first named agent
IV-2-1	Name(s)	FUSE, Yukio; OFUCHI, Michie
V	Designation of States	
V-1	Regional Patent (other kinds of protection or treatment, if any, are specified between parentheses after the designation(s) concerned)	--
V-2	National Patent (other kinds of protection or treatment, if any, are specified between parentheses after the designation(s) concerned)	KR SG US
V-5	Precautionary Designation Statement In addition to the designations made under items V-1, V-2 and V-3, the applicant also makes under Rule 4.9(b) all designations which would be permitted under the PCT except any designation(s) of the State(s) indicated under item V-6 below. The applicant declares that those additional designations are subject to confirmation and that any designation which is not confirmed before the expiration of 15 months from the priority date is to be regarded as withdrawn by the applicant at the expiration of that time limit.	
V-6	Exclusion(s) from precautionary designations	NONE
VI-1	Priority claim of earlier national application	
VI-1-1	Filing date	26 March 1998 (26.03.1998)
VI-1-2	Number	10-079874
VI-1-3	Country	JP
VII-1	International Searching Authority Ch sen	

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VIII	Check list	number of sheets	electronic fil (s) attached
VIII-1	Request	3	-
VIII-2	Description	10	-
VIII-3	Claims	4	-
VIII-4	Abstract	1	-
VIII-5	Drawings	6	-
VIII-7	TOTAL	24	
	Accompanying items	paper document(s) attached	electronic file(s) attached
VIII-8	Fee calculation sheet	✓	-
VIII-16	PCT-EASY diskette	-	diskette
VIII-18	Figure of the drawings which should accompany the abstract	1	
VIII-19	Language of filing of the international application	Japanese	
IX	Signature of applicant or agent		
IX-1	Name (LAST, First)		
IX-2	Capacity		

FOR RECEIVING OFFICE USE ONLY

10-1	Date of actual receipt of the purported international application	
10-2	Drawings:	
10-2-1	Received	
10-2-2	Not received	
10-3	Corrected date of actual receipt due to later but timely received papers or drawings completing the purported international application	
10-4	Date of timely receipt of the required corrections under PCT Article 11(2)	
10-5	International Searching Authority	
10-6	Transmittal of search copy delayed until search fee is paid	

FOR INTERNATIONAL BUREAU USE ONLY

11-1	Date of receipt of the record copy by the International Bureau	
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